

INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

June 18, 2025

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

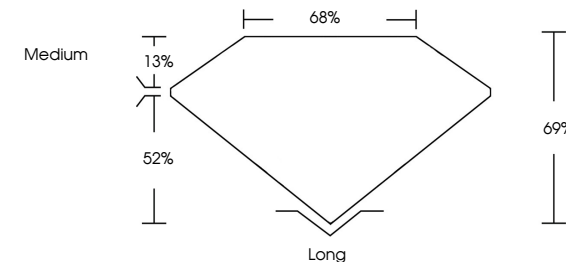
Inscription(s)

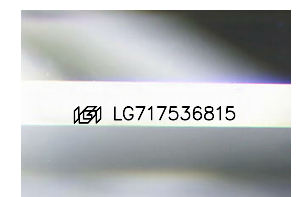
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG717536815

Report verification at [igi.org](https://www.igi.org)

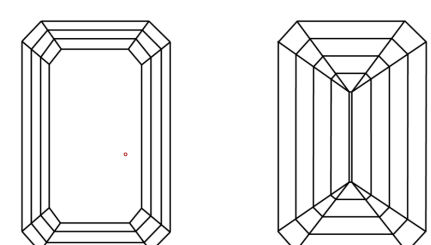
PROPORTIONS





Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D

E

F

G

H

I

J

Faint

Very Light

Light

CLARITY

IF

VS¹⁻²

VS¹⁻²

SI¹⁻²

I¹⁻³

Internally Flawless


Very Very Slightly Included

Very Slightly Included

Slightly Included

Included

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LABORATORY GROWN DIAMOND

EMERALD CUT

14.62 X 10.04 X 6.93 MM

10.04 CARATS


F

VS 1

EXCELLENT

EXCELLENT

NONE

 IGI

June 18, 2025

IGI Report No LG717536815

EMERALD CUT

14.62 X 10.04 X 6.93 MM

10.04 CARATS

F

VS 1

68%

69%


Medium

Long

EXCELLENT

EXCELLENT



NONE

 IGI

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